

Fig.10(A) FORMATION OF PROTECTIVE INSULATION FILM

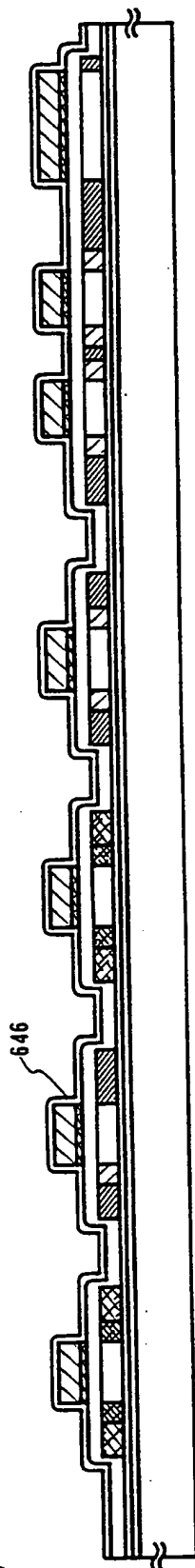


Fig.10(B) ACTIVATION STEP

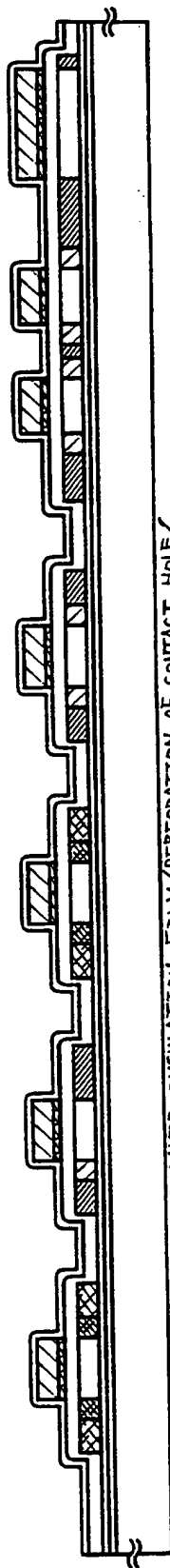
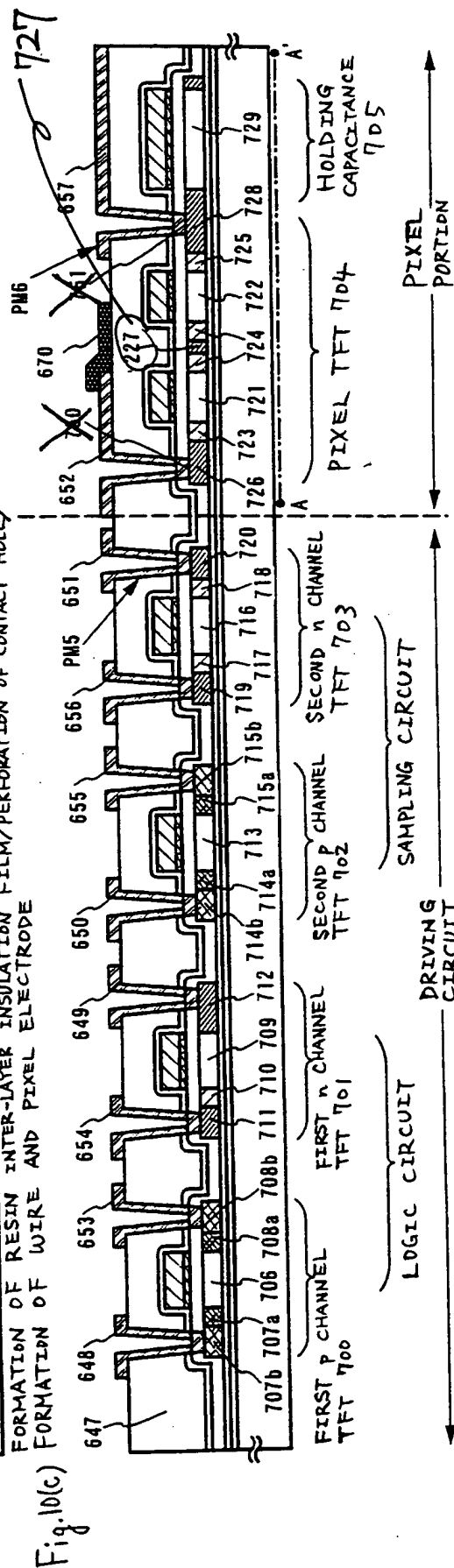


Fig.10(C) FORMATION OF RESIN INTER-LAYER INSULATION FILM/PERFORATION OF CONTACT HOLE/
FORMATION OF WIRE AND PIXEL ELECTRODE



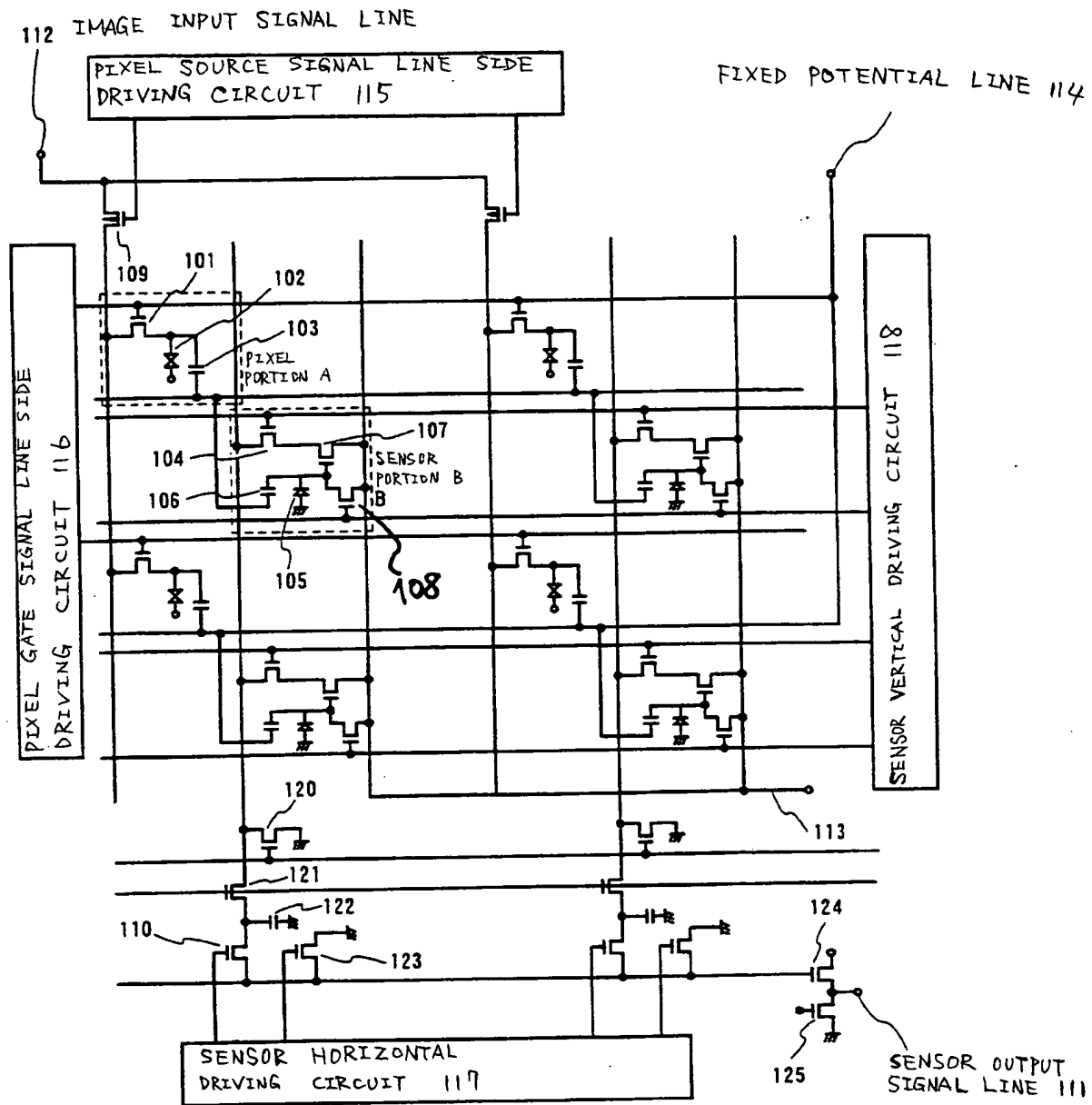


Fig. 14